

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re New National Phase Application of)
Hiroyuki TOMIZAWA et al.)
International Application PCT/JP2004/003150) Attn: US/DO/EO
Internationally Filed: March 10, 2004)
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PROCESS FOR PRODUCING THE SAME) Date: March 15, 2005

PRELIMINARY AMENDMENT

United States Patent and Trademark Office
Customer Service Window
Randolph Building
401 Dulany Street
Alexandria, VA 22314

Sir:

Please preliminarily amend the subject application as follows: